



Bib Data Sheet


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<b>SERIAL NUMBER</b> 08/958,460	<b>FILING DATE</b> 10/28/1997 <b>RULE</b> -	<b>CLASS</b> 216	<b>GROUP ART UNIT</b> 1711	<b>ATTORNEY DOCKET NO.</b> UMC-96-279
<b>APPLICANTS</b> CHIH-CHEN LIU, TAIPEI, TAIWAN; TA-SHAN TSENG, TAIPEI, TAIWAN; WEN-BIN SHIEH, HSIN-CHU CITY, TAIWAN; JUAN-YUAN WU, HSIN-CHU CITY, TAIWAN; WATER LUR, TAIPEI, TAIWAN; SHIH-WEI SUN, TAIPEI, TAIWAN;				
<b>** CONTINUING DATA *****</b> THIS APPLN CLAIMS BENEFIT OF 60/041,790 04/02/1997				
<b>** FOREIGN APPLICATIONS *****</b>				
Foreign Priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 (a-d) conditions met <input type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> Met after Allowance Verified and Acknowledged <input type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> Met after Allowance		<b>STATE OR COUNTRY</b> TAIWAN	<b>SHEETS DRAWING</b> 4	<b>TOTAL CLAIMS</b> 20
Examiner's Signature _____ Initials _____		<b>INDEPENDENT CLAIMS</b> 3		
<b>ADDRESS</b> 23995				
<b>TITLE</b> HIGH DENSITY PLASMA CHEMICAL VAPOR DEPOSITION PROCESS				
<b>FILING FEE RECEIVED</b> 790	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:		<input type="checkbox"/> All Fees <input type="checkbox"/> 1.16 Fees ( Filing ) <input type="checkbox"/> 1.17 Fees ( Processing Ext. of time ) <input type="checkbox"/> 1.18 Fees ( Issue ) <input type="checkbox"/> Other _____ <input type="checkbox"/> Credit	